

Iso-oriented monolayer α - $\text{MoO}_3(010)$ films epitaxially grown on $\text{SrTiO}_3(001)$

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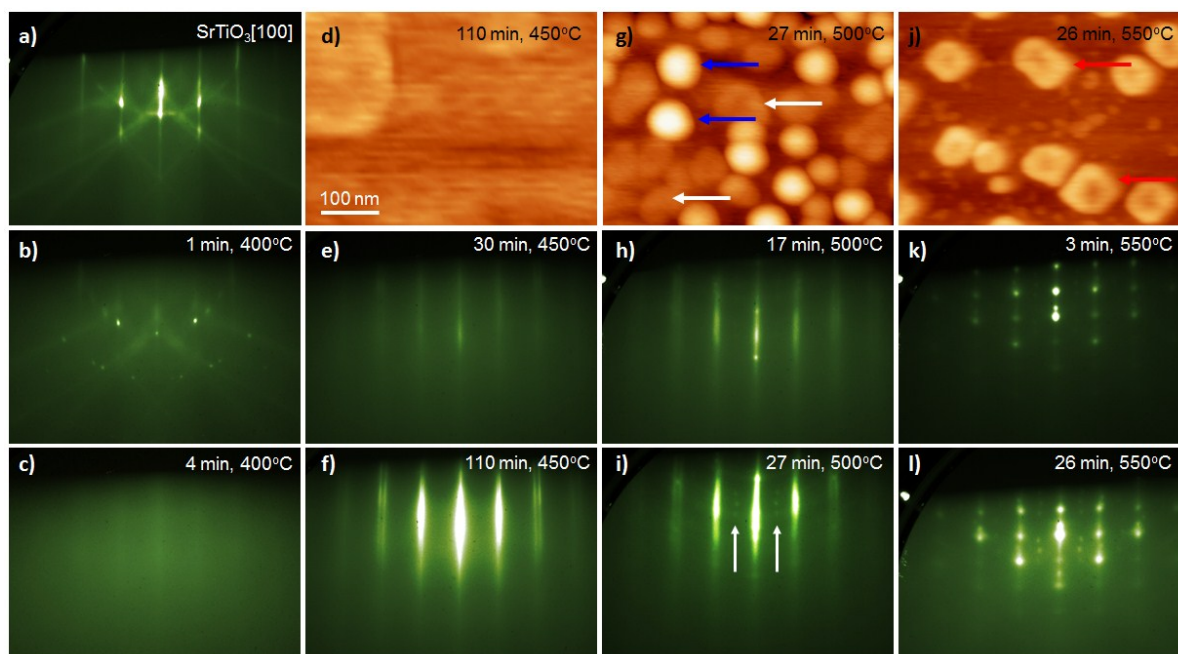


Figure s1: RHEED patterns taken along [100] azimuthal direction and AFM images (d, g, and j) of MoO_3 films grown on $\text{SrTiO}_3(001)$. Total deposition time and substrate temperature for each film are marked.

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† Electronic Supplementary Information (ESI) available: See

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